

Accepted Manuscript

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PII: S0167-577X(18)31070-X
DOI: <https://doi.org/10.1016/j.matlet.2018.07.039>
Reference: MLBLUE 24605

To appear in: *Materials Letters*

Received Date: 19 April 2018
Revised Date: 8 July 2018
Accepted Date: 10 July 2018

Please cite this article as: Q. Chen, R. He, Q. Liu, Y. Wang, H. Jin, W. Xie, Rapid preparation of large size, few-layered MoO₃ by anisotropic etching, *Materials Letters* (2018), doi: <https://doi.org/10.1016/j.matlet.2018.07.039>

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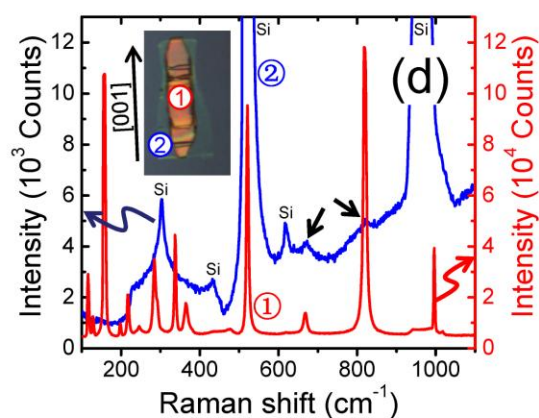
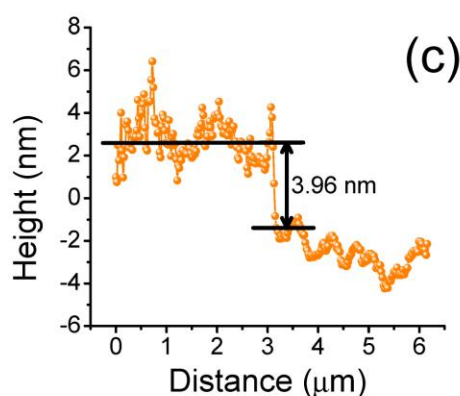
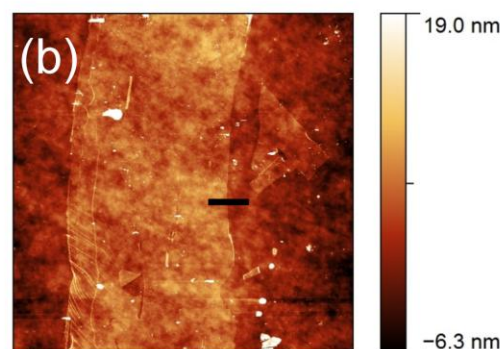
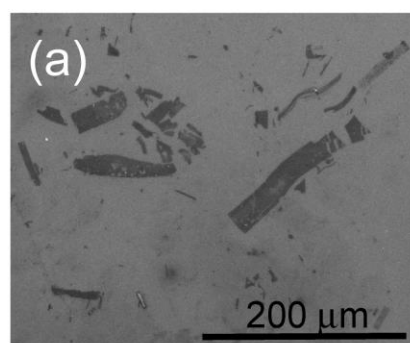


Rapid preparation of large size, few-layered MoO₃ by anisotropic etching

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Abstract

Preparation of large size, few-layered (FL) 2D materials is one of the challenging

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